Application No.: 10/568,075

Art Unit: 2831

AMENDMENTS TO THE CLAIMS

This listing of claims replaces all prior versions of claims in the application.

1. (Original): A hermetic sealing cap (1) employed for an electronic component storage

package including an electronic component storing member (10) for storing an electronic

component (20), comprising:

a substrate (2);

a first layer (3), formed on the surface of said substrate, mainly composed of Ni

containing a diffusion accelerator;

a second layer (4) formed on the surface of said first layer; and

a solder layer (5) mainly composed of Sn formed on a region of the surface of said second

layer to which said electronic component storing member is bonded, wherein

said second layer has a function of inhibiting said first layer from diffusing into said

solder layer at a first temperature while diffusing said first layer into said solder layer through

said second layer when said solder layer bonds to said electronic component storing member at a

second temperature higher than said first temperature.

2. (Original): The hermetic sealing cap according to claim 1, wherein

said first temperature is a temperature at a time of forming said solder layer by melting

solder paste (6), and

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said second temperature is a temperature at a time of bonding said hermetic sealing cap to said electronic component storing member by melting said solder layer.

- 3. (Currently Amended): The hermetic sealing cap according to claim 1 [[or 2]], wherein said second layer is made of Ni.
- 4. (Original): The hermetic sealing cap according to claim 3, wherein said second layer has a thickness of at least 0.03 μm and not more than 0.075 μm .
- 5. (Currently Amended): The hermetic sealing cap according to any of claims 1 to 4 claim 1, wherein

said first layer contains 7.5 mass % to 20 mass % of Co as said diffusion accelerator.

6. (Currently Amended): The hermetic sealing cap according to any of claims 1 to 5 claim 1, wherein

said substrate is made of an Fe-Ni-Co alloy.

7. (Currently Amended): The hermetic sealing cap according to any of claims 1 to 6 claim 1, wherein

said first layer and said second layer are formed by plating.

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8. (Original): The hermetic sealing cap according to claim 7, wherein

said first layer is formed on the whole area of the surface of said substrate, and

said second layer is formed on the whole area of the surface of said first layer.

9. (Currently Amended): The hermetic sealing cap according to any of claims 1 to 8

claim 1, wherein

said solder layer contains no Pb, and contains Ag.

10. (Original): An electronic component storage package including an electronic

component storing member (10) for storing an electronic component (20), comprising:

a hermetic sealing cap (1) including a substrate (2), a first layer (3), formed on the surface

of said substrate, mainly composed of Ni containing a diffusion accelerator, a second layer (4)

formed on the surface of said first layer and a solder layer (5) mainly composed of Sn formed on

a region of the surface of said second layer to which said electronic component storing member is

bonded, with said second layer having a function of inhibiting said first layer from diffusing into

said solder layer at a first temperature while diffusing said first layer into said solder layer

through said second layer when said solder layer bonds to said electronic component storing

member at a second temperature higher than said first temperature, wherein

a third layer (14) is formed on a portion of said electronic component storing member

corresponding to said solder layer,

said solder layer and said third layer are bonded to each other, and

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an intermetallic compound (7) containing Sn of said solder layer is formed on the junction between said hermetic sealing cap and said electronic component storing member.

11. (Original): The electronic component storage package according to claim 10, wherein

the junction between said hermetic sealing cap and said electronic component storing

member contains an intermetallic compound consisting of an Ni-Sn alloy, and

a portion of said second layer corresponding to the junction between said hermetic sealing

cap and said electronic component storing member diffuses in said intermetallic compound.

12. (Original): A method of manufacturing a hermetic sealing cap (1) employed for an

electronic component storage package including an electronic component storing member (10)

for storing an electronic component, comprising steps of:

preparing a substrate (2);

forming a first layer (3) mainly composed of Ni containing a diffusion accelerator on the surface of said substrate;

forming a second layer (4) on the surface of said first layer; and

forming a solder layer (5) mainly composed of Sn on a region of the surface of said

second layer to which said electronic component storing member is bonded, wherein

the step of forming said second layer includes a step of forming the second layer having a

function of inhibiting said first layer from diffusing into said solder layer when forming said

solder layer at a first temperature while diffusing said first layer into said solder layer through

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said second layer when said solder layer bonds to said electronic component storing member at a second temperature higher than said first temperature.

13. (Original): The method of manufacturing a hermetic sealing cap according to claim 12, wherein

the step of forming said solder layer includes steps of arranging solder paste (6) mainly composed of Sn on a region of the surface of said second layer to which said electronic component storing member is bonded and forming said solder layer mainly composed of said Sn

by melting said solder paste at said first temperature.

14. (Currently Amended): The method of manufacturing a hermetic sealing cap

according to claim 12 [[or 13]], wherein

said second layer is made of Ni.

15. (Original): The method of manufacturing a hermetic sealing cap according to claim

14, wherein

said second layer has a thickness of at least 0.03 μm and not more than 0.075 μm .

16. (Currently Amended): The method of manufacturing a hermetic sealing cap

according to any of claims 12 to 15 claim 12, wherein

said first layer contains 7.5 mass % to 20 mass % of Co as said diffusion accelerator.

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17. (Currently Amended): The method of manufacturing a hermetic sealing cap according to any of claims 12 to 16 claim 12, wherein

said substrate is made of an Fe-Ni-Co alloy.

18. (Currently Amended): The method of manufacturing a hermetic sealing cap according to any of claims 12 to 17 claim 12, wherein

the step of forming said first layer includes a step of forming said first layer by plating, and

the step of forming said second layer includes a step of forming said second layer by plating.

19. (Original): The method of manufacturing a hermetic sealing cap according to claim 18, wherein

the step of forming said first layer by plating includes a step of forming said first layer on the whole area of the surface of said substrate, and

the step of forming said second layer by plating includes a step of forming said second layer on the whole area of the surface of said first layer.

20. (Currently Amended): The method of manufacturing a hermetic sealing cap according to any of claims 12 to 19 claim 12, wherein

said solder layer contains no Pb, and contains Ag.